

U.S. Department of Commerce, Patent and Trademark Office					Atty Docket No.		Serial No.	
					M-12347 US		N A	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT					Applicants			
(Use several sheets if necessary)					Paul E. Brunemeier, Archita Sengupta, Justin F. Gaynor, Robert H. Haveman			
					Filing Date		Group	
					Herewith		N A	
U.S. Patent Documents								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA	6,329,062 B1	12/11/02	Gaynor	428	447		
	AB	6,260,949 B1	7/17/01	Smith, et al.	347	44		
	AC							
	AD							
	AE							
	AF							
	AG							
	AH							
	AI							
Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
	AJ	9-230600	9/5/97	Japan	H01L	21/30	X	
	AK	2000-199963	7/18/00	Japan	H01L	21/30	X	
	AL	2000-199962	7/18/00	Japan	H01L	21/30	X	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
	AM	Kikkawa, Takamaro, "Proceedings of the International Electronic Devices Meeting," 12/10-13/00, pp. 253-256.						
	AN	Levy, David, "Electrooptical Devices from Organically Doped sol-Gel Materials," Mol. Cryst. And Liq. Cryst. 1000, Vol. 354, pp. 159-165.						
	AO	Katz, Alexander and Davis, Mark E., "Molecular imprinting of bulk microporous silica, Nature Vol 403 20 January 2000.						
	AP	Jalone, Paavo and Tuominen, Aulis, "The Applicability of Electrodeposited Photoresist in Producing Ultra-fine Lines Using Sputtered Seeding Layers," IEEE 2000 Int'l. Symp on Electronic Materials &						

10/0922201
03/04/02

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Date Considered

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through
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